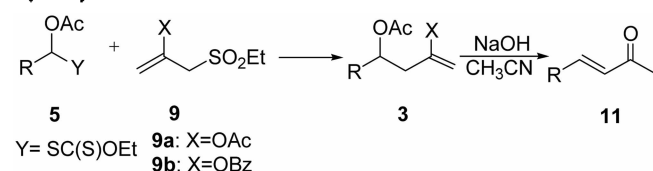
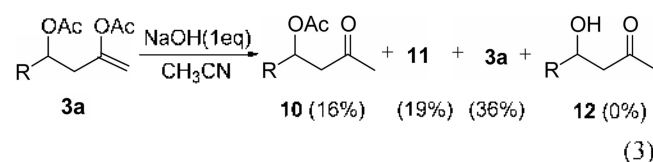
**Scheme 2.** Preparation of  $\alpha,\beta$ -unsaturated ketone **11** from **5** and **9**.**Table 1.** Tin-free Allylation of **5** with Allyl Sulfone **9** and Hydrolysis of **3** to **11**<sup>a</sup>

xanthate <b>5</b>	allylation product <b>3</b>	enone <b>11</b>
	 X=OAc 74% X=OBz 71%	 82% 87%
	 X=OAc 72% X=OBz 69%	 72% 85%
	 X=OAc 66% X=OBz 68%	 75% 86%

<sup>a</sup>1 equiv of lauroyl peroxide in dichloroethane, 90 °C, 6 h

92% yield (Scheme 1). A similar result was obtained with **6b**. When the reaction was carried out with 2-acetoxy allyl ethyl sulfone (**9a**) under the same condition, the desired product **10a** was isolated in 74% yield (Scheme 2). Further experimental results are listed in Table 1 and illustrate the synthetic utility of the present approach. Secondary and tertiary alkyl substituted xanthates worked well, yielding  $\beta$ -acetoxy vinyl acetates and vinyl benzoates in good yields. Hydrolysis of enol acetate **3a** with 1 N NaOH (1 equiv) in acetonitrile at room temperature for 9 h gave a mixture of **10** and **11** along with the starting material **3a** (eq. 3). The use of an excess amount of NaOH (5 eq) gave  $\alpha,\beta$ -unsaturated ketone **11** in 82% yield without yielding  $\beta$ -hydroxy ketone **12**.



In conclusion, we have developed new tin-free radical

allylation approaches to  $\alpha,\beta$ -unsaturated ketones using  $\alpha$ -acetoxy alkyl xanthates **5** as radical precursors and 2-acetoxy and 2-benzoyloxy allyl ethyl sulfone as radical acceptors.

**Acknowledgment.** We thank CMDS and BK21 project for financial support.

## References

- For reviews, see: (a) Curran, D. P. *Synthesis* **1988**, 489. (b) Rosenstein, I. J. In *Radicals in Organic Synthesis*; Renaud, P.; Sibi, M. P., Eds.; Wiley-VCH: Weinheim, Germany, 2001; Vol. 1, p 50.
- (a) Keck, G. E.; Enholm, E. J.; Yates, J. B.; Wiley, M. R. *Tetrahedron* **1985**, *41*, 4079. (b) Mizuno, K.; Ikeda, M.; Toda, S.; Otsuji, Y. *J. Am. Chem. Soc.* **1988**, *110*, 1288. (c) Miura, K.; Itoh, D.; Hondo, T.; Saito, H.; Ito, H.; Hosomi, A. *Tetrahedron Lett.* **1996**, *37*, 8539.
- (a) Keck, G. E.; Byers, J. H. *J. Org. Chem.* **1985**, *50*, 5442. (b) Curran, D. P.; Yoo, B. *Tetrahedron Lett.* **1992**, *33*, 6931.
- (a) Ueno, Y.; Aoki, S.; Okawara, M. *J. Chem. Soc., Chem. Commun.* **1980**, 683. (b) Smith, T. A. K.; Whitham, G. H. *Chem. Commun.* **1985**, 897. (c) Padwa, A.; Kline, D. N.; Murphree, S. S.; Yeske, P. E. *J. Org. Chem.* **1992**, *57*, 298. (d) Chatgililoglu, C.; Alberti, A.; Ballestri, M.; Macciantelli, D. *Tetrahedron Lett.* **1996**, *37*, 6391.
- (a) Garner, P.; Leslie, R.; Anderson, J. T. *J. Org. Chem.* **1996**, *61*, 6754. (b) Garner, P.; Anderson, J. T. *Org. Lett.* **1999**, *1*, 1057. (c) Garner, P.; Anderson, J. T.; Cox, P. B.; Klippenstein, S. J.; Leslie, R.; Scardovi, N. *J. Org. Chem.* **2002**, *67*, 6195.
- (a) Lee, E.; Tac, J. S.; Lee, C.; Park, C. M. *Tetrahedron Lett.* **1993**, *34*, 4831. (b) Lee, E.; Yoo, S. K.; Choo, H.; Song, H. Y. *Tetrahedron Lett.* **1998**, *39*, 317.
- (a) Sibi, M. P.; Zimmerman, J.; Rheault, T. *Angew. Chem. Int. Ed.* **2003**, *42*, 4521. (b) Sibi, M. P.; Patil, K. *Org. Lett.* **2005**, *7*, 1453.
- (a) Appleyard, G. D.; Stirling, C. J. M. *J. Chem. Soc., Chem. Commun.* **1967**, 2686. (b) Ueno, Y.; Ohta, M.; Okawara, M. *J. Organomet. Chem.* **1980**, *197*, C1.
- Chou, T. S.; Knochel, P. *J. Org. Chem.* **1990**, *55*, 4791.
- Sun, S.; Curran, D. P. *Tetrahedron Lett.* **1991**, *32*, 6097.
- (a) Neuenschwander, M.; Bigler, P.; Christen, K.; Iseli, R.; Kyburz, R.; Muhle, H. *Helv. Chim. Acta* **1978**, *61*, 2047. (b) Knochel, P.; Chou, T. S.; Jubert, C.; Rajagopal, D. *J. Org. Chem.* **1993**, *58*, 588.
- For our previous reports on tin-free radical reactions, see (a) Kim, S.; Lim, C. J. *Angew. Chem. Int. Ed.* **2002**, *41*, 3265. (b) Kim, S.; Lim, C. J. *Bull. Korean Chem. Soc.* **2003**, *24*, 1219. (c) Kim, S.; Lee, S.; Lim, C. J. *Bull. Korean Chem. Soc.* **2004**, *25*, 1611. (d) Kim, S.; Kim, S.; Otsuka, N.; Ryu, I. *Angew. Chem.* **2005**, *117*, 6339.
- (a) Quiclet-Sire, B.; Zard, S. Z. *J. Am. Chem. Soc.* **1996**, *118*, 1209. (b) Bertrand, F.; Quiclet-Sire, B.; Seguin, S.; Zard, S. Z. *J. Am. Chem. Soc.* **1997**, *119*, 7410.
- Zard, S. Z. *Angew. Chem. Int. Ed.* **1997**, *36*, 672. (b) Forbes, J. E.; Zard, S. Z. *J. Am. Chem. Soc.* **1990**, *112*, 2034. (c) Sire, B.; Seguin, S.; Zard, S. Z. *Angew. Chem. Int. Ed.* **1998**, *37*, 2864.